

4/16/04

**ELECTRONIC INFORMATION DISCLOSURE STATEMENT**

Electronic Version v18

Stylesheet Version v18.0

**Title of  
Invention****METHOD OF FABRICATING A CMOS DEVICE WITH DUAL  
METAL GATE ELECTRODES**

Application Number : 10/826665  
Confirmation Number: 9608  
First Named Applicant: CHANG PARK  
Attorney Docket Number: 61472-0308425  
Art Unit:  
Examiner:  
Search string: ( 6653698 or 6352913 ).pn

**US Patent Documents****Note: Applicant is not required to submit a paper copy of cited US Patent Documents**

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
MDP	1	6653698	2003-11-25	LEE ET AL.	B2	257	407
MDP	2	6352913	2002-03-05	MISTRY ET AL.	B1	438	587

**Signature**

Examiner Name	Date
<i>Christopher D. Hansen</i>	3/17/06